

35.C10530C/D2

#2  
Pre Amended  
7.29.99  
Ryf  
PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
KIYOFUMI SAKAGUCHI ET AL. ) Examiner: NYA  
Divisional of )  
Application No.: 08/863,717 ) Group Art Unit: NYA  
Filed: Herewith )  
For: PROCESS FOR PRODUCTION )  
OF SEMICONDUCTOR )  
SUBSTRATE ) September 28, 1998

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

Preliminary to the examination on the merits,  
please amend the above-identified application as follows:

IN THE CLAIMS:

Please cancel claims 1-21 without prejudice or  
disclaimer.

Please add the following new claims 22-96:

--22. A process for producing a semiconductor  
substrate comprising the steps of: